

# EUV Lithography Market Growth, Trends & Forecast 2024-2031 | Advanced Semiconductor Technology

*The EUV Lithography Market is growing fast, driven by demand for advanced semiconductors in AI, 5G, and high-performance chip manufacturing.*

AUSTIN, TX, UNITED STATES, May 28, 2025 /EINPresswire.com/ -- EUV Lithography Market Overview

The [EUV lithography Market Size](#) is anticipated to expand at a compound annual growth rate (CAGR) of 12% between 2024 and 2031.



The image shows the cover of a report titled "EUV Lithography Market" by Data Intelligence. The cover features a photograph of a semiconductor manufacturing machine with a purple light effect. The Data Intelligence logo is at the top left. Below the photo is the email address "Info@datamintelligence.com". To the right of the photo, the title "EUV Lithography Market" is displayed, followed by a dashed line and the section "Key Benefits of Market". Below this, three bullet points are listed: "Actionable Market Insights", "Competitive Intelligence Reports", and "Accelerate Market Entry".

Extreme Ultraviolet (EUV) lithography is transforming the way semiconductors are produced. It has become a cornerstone technology for advanced chip manufacturing, enabling manufacturers to create incredibly small and powerful components. As industries increasingly rely on high-performance computing, AI, 5G, and other next-generation technologies, the demand for advanced chips continues to surge making EUV lithography a vital component of this future.

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EUV lithography is revolutionizing chipmaking in the U.S., driven by rising AI and 5G demands, with billions invested in domestic semiconductor manufacturing by 2025”

*DataM Intelligence*

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By 2025, the EUV lithography market is seeing substantial traction, valued in the multi-billion-dollar range and expected to continue expanding at a strong pace. The growth can largely be attributed to rapid advancements in

semiconductor technologies and a global push to reduce chip sizes while increasing processing power and energy efficiency. EUV's ability to deliver precise patterns at nanoscales gives it a

unique edge over traditional lithography methods.

## Market Growth and Demand Drivers

The increasing need for more powerful processors is fueling investments in EUV lithography tools across the globe. Leading chipmakers are under pressure to produce faster, more efficient semiconductors, and EUV technology helps them meet these evolving requirements. Unlike older lithography techniques that use deep ultraviolet light, EUV uses much shorter wavelengths, which allows for more detailed etching on silicon wafers.

One of the most important advantages of EUV is its ability to reduce the number of manufacturing steps, which not only cuts production time but also enhances precision and minimizes potential defects. As consumer electronics, automotive systems, and industrial machinery become smarter and more interconnected, the demand for smaller, better chips keeps rising pushing the EUV market forward.

## Regional Outlook

The Asia-Pacific region currently dominates the EUV lithography market, thanks to its strong manufacturing base and robust investments in semiconductor production. Countries like South Korea, Taiwan, and China are continually scaling up their infrastructure to support this sophisticated technology.

North America, particularly the United States, is also emerging as a key growth area. With significant federal and private investments in semiconductor R & D, the region is witnessing a renaissance in domestic chip production. Meanwhile, Europe plays a pivotal role, with certain players contributing high-precision EUV equipment and essential components.

## Key Market Players

ASML  
Canon Inc.  
Intel Corporation  
Nikon Corporation  
NuFlare Technology Inc.  
Samsung Corporation  
SUSS Microtec AG  
Taiwan Semiconductor Manufacturing Company Limited (TSMC)  
Ultratech Inc.  
Vistec Semiconductor Systems

Market Segmentation:

By Light Source: Laser Produced Plasma, Vacuum Sparks, Gas Discharges

By Application: Integrated Device Manufacturer, Foundry

By Equipment: Light Source, Mirrors, Masks, Others

By Region: North America, Latin America, Europe, Asia Pacific, Middle East, and Africa

## Latest News of USA

The United States has made notable strides in supporting the growth of EUV lithography within its borders. One of the most prominent recent developments is the construction and expansion of advanced semiconductor facilities, aiming to restore domestic chip-making capabilities. With national security and technological independence being top priorities, the U.S. government is heavily supporting initiatives that focus on next-generation manufacturing processes, including EUV.

There's also growing concern around the export of EUV technology to certain foreign markets. This reflects a larger strategic discussion within the U.S. on how to balance economic cooperation with maintaining leadership in critical technologies. These debates, while political in nature, also reflect just how central EUV lithography has become to the country's long-term industrial strategy.

Additionally, major U.S.-based chip manufacturers are investing heavily in upgrading their production lines with EUV capabilities, recognizing that the technology is no longer optional but essential for staying competitive globally.

## Latest News of Japan

Japan, known for its technical precision and innovation, is stepping up its focus on EUV lithography in a significant way. The country is rapidly advancing its domestic chip production through the development of next-gen fabrication plants equipped with EUV tools. One of the latest milestones involves the installation of cutting-edge EUV machinery in newly developed facilities, aimed at mass-producing highly sophisticated semiconductors.

This effort isn't just about keeping up; it's about regaining leadership in a domain where Japan has historically been strong. By focusing on high-end chip production and integrating EUV technologies, Japanese companies are positioning themselves to meet both domestic and global demand.

Government backing has also been a critical part of this movement. By aligning public and private sector efforts, Japan is ensuring that its companies have the tools, funding, and talent needed to scale EUV capabilities. These steps not only support the country's economic goals but

also contribute to the global supply chain's stability and resilience.

## Conclusion

The EUV lithography market is on a strong upward trajectory. With growing needs across sectors like AI, mobile technology, and automotive electronics, EUV is no longer a luxury it's a necessity. Its unique ability to improve chip density and performance while reducing energy consumption makes it the technology of choice for future-ready semiconductor manufacturing.

Both the U.S. and Japan are making aggressive moves to lead or maintain their positions in this space. Their efforts reflect a broader realization: controlling EUV capabilities is not just about business it's about future-proofing national industries and staying competitive in the global tech race. As we move closer to 2030, the influence of EUV lithography will only grow stronger, shaping not just chips, but the entire digital future.

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